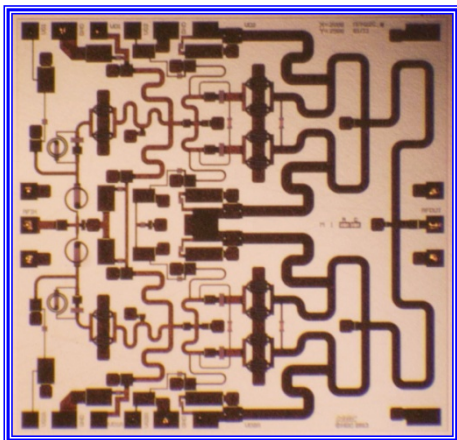
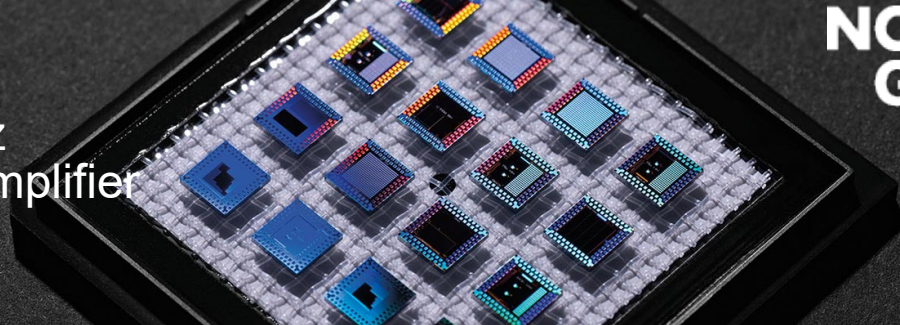


**APN226**  
**13.5-15.5 GHz**  
**GaN Power Amplifier**



**X = 2.6 mm Y = 2.5 mm**

**Product Features**

- RF frequency: 13.5 to 15.5 GHz
- Linear Gain: 20 typ.
- Psat: 39 dBm typ.
- Die Size: 6.5 sq. mm
- 0.2 um GaN HEMT Process
- 4 mil SiC substrate
- DC Power: 24 VDC @ 880 mA

**Applications**

- Point-to-Point Digital Radios
- Point-to-Multipoint Digital Radios
- SATCOM Terminals

**Product Description**

The APN226 monolithic GaN HEMT amplifier is a broadband, two-stage power device, designed for use in SATCOM Terminals and point-to-point digital radios. To ensure rugged and reliable operation, HEMT devices are fully passivated. Both bond pad and backside metallization are Au-based that is compatible with epoxy and eutectic die attach methods.

**Performance Characteristics (Ta = 25°C)**

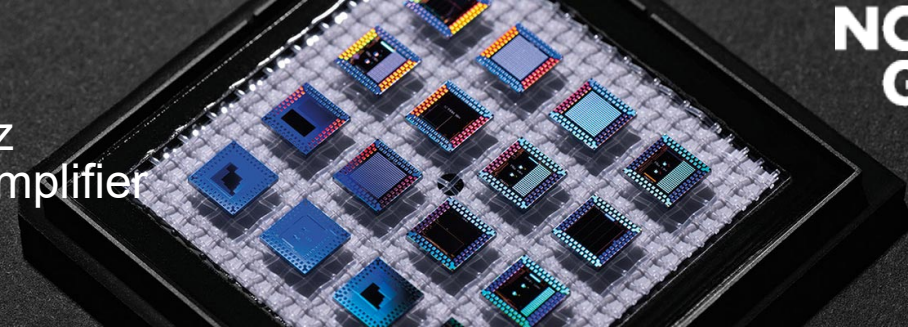
Specification	Min	Typ	Max	Unit
Frequency	13.5		14	GHz
Linear Gain	19	20		dB
Input Return Loss	9.5	12		dB
Output Return Loss	9.5	12		dB
P1dB (PP*)		36.5		dBm
Psat (PP*)	38.5	39.5		dBm
PAE @ Psat (PP*)		27		%
Vd1, Vd2		24		V
Vg1, Vg2		-3.5		V
Id1		240		mA
Id2		640		mA

**Export Information**

ECCN: **5A991.g**  
 HTS (Schedule B) code: **8542.33.0000**

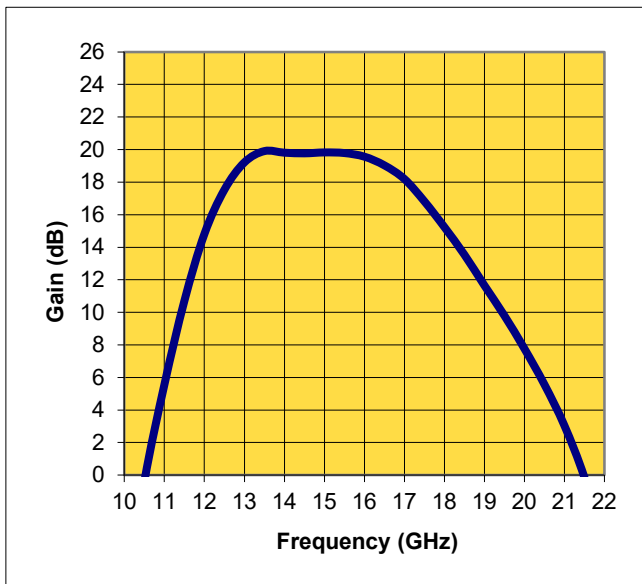
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## APN226 13.5-15.5 GHz GaN Power Amplifier

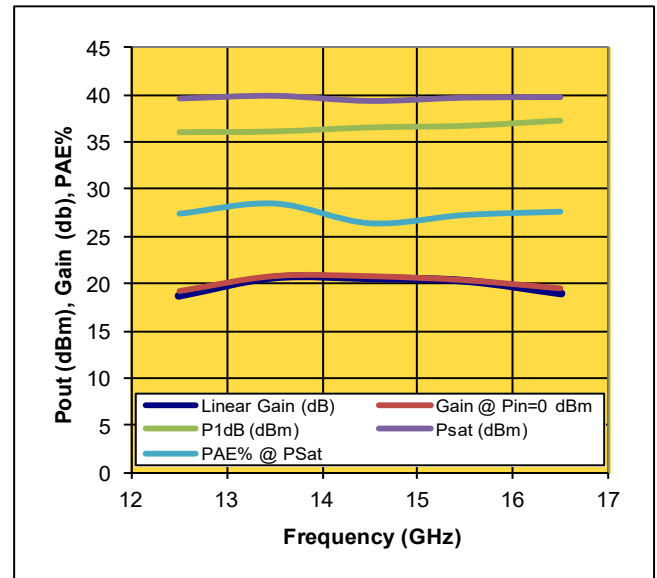


**On wafer measured Performance Characteristics (Typical Performance at 25°C)**  
**Vd1 = Vd2 = 24 V, Id1 = 240 mA, Id2 = 640 mA. \***

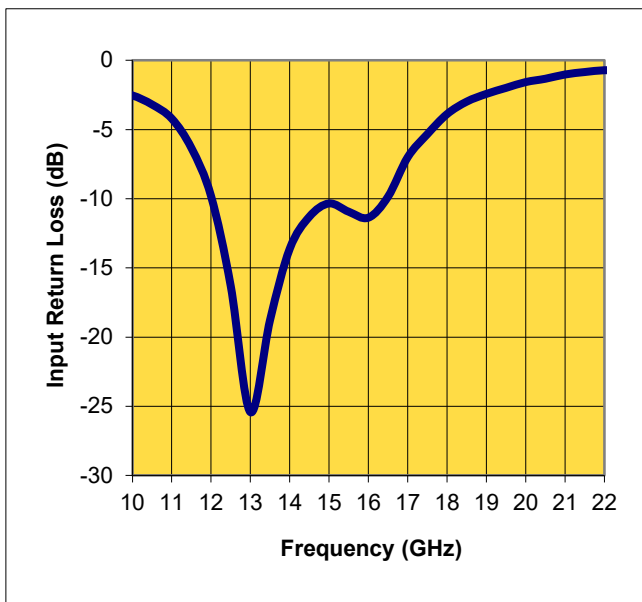
GAIN vs. Frequency



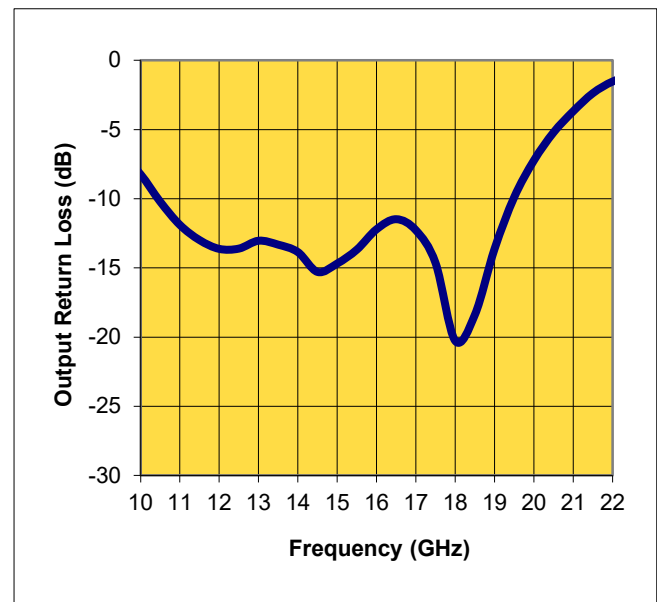
PAE, GAIN, Pout vs. Frequency



Input Return Loss vs. Frequency



Output Return Loss vs. Frequency

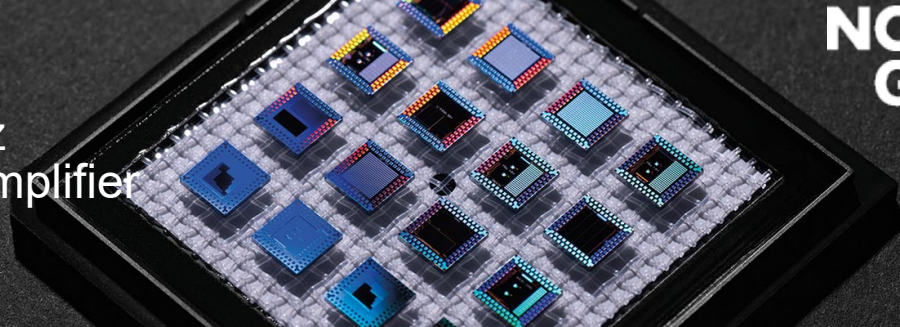


\*Pulsed-power on-wafer

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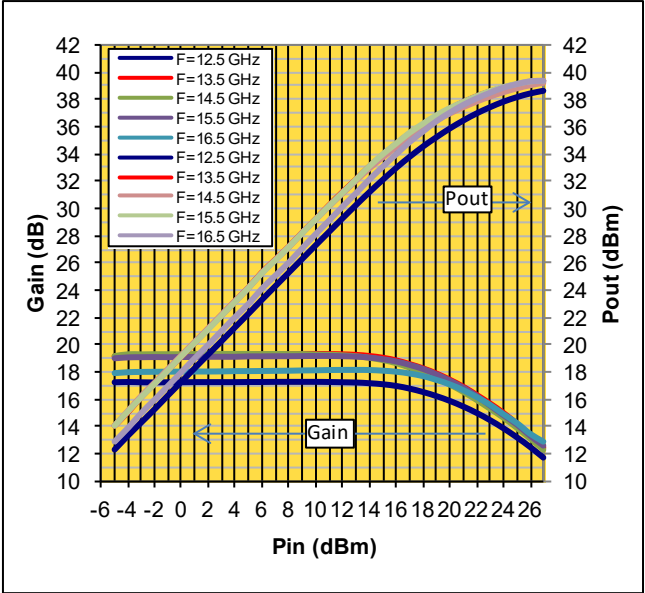


## APN226 13.5-15.5 GHz GaN Power Amplifier

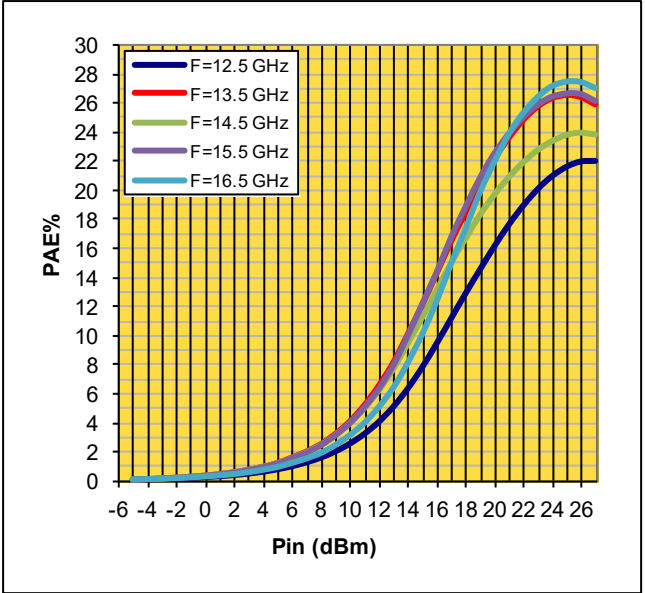


### Measured Fixtured Performance Characteristics (Typical Performance at 25°C) Vd1 = Vd2 = 24 V, Id1 = 240 mA, Id2 = 640 mA.

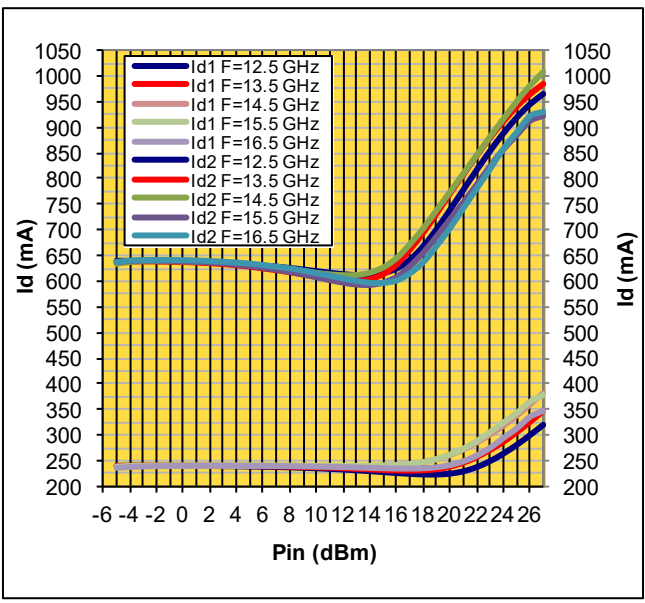
GAIN, Pout vs. Pin



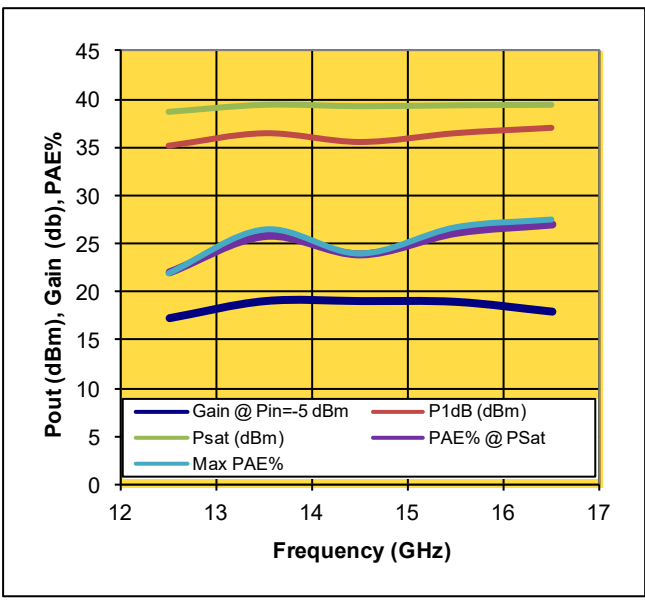
PAE vs. Pin



Id vs Pin



Pout, Gain, PAE vs. Frequency



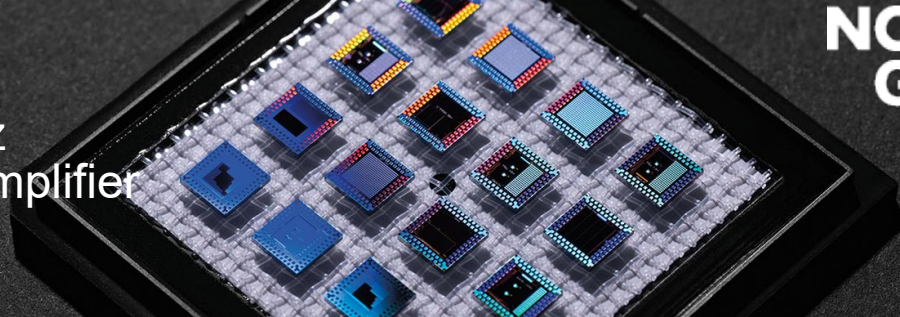
\*\* CW fixtured

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# APN226

## 13.5-15.5 GHz

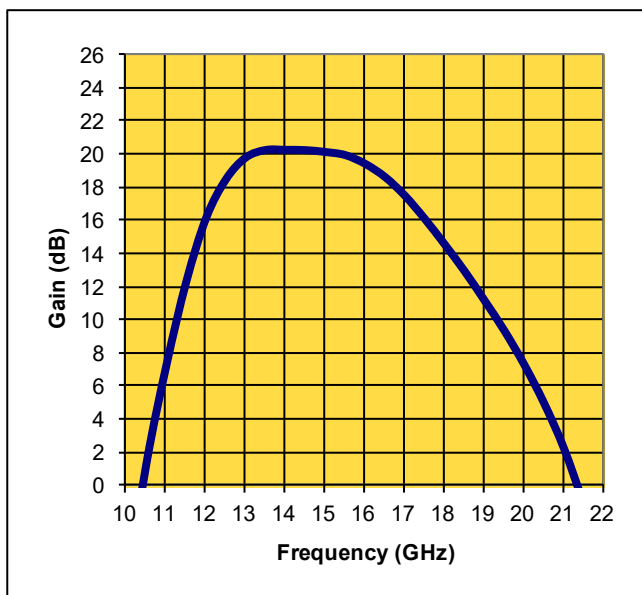
### GaN Power Amplifier



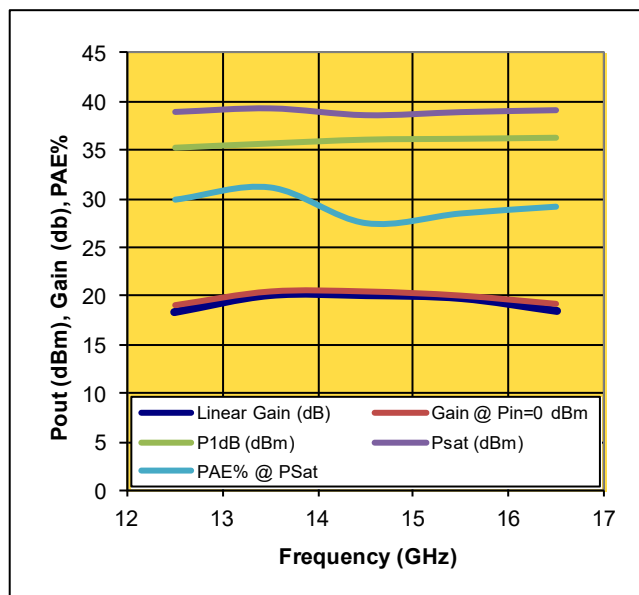
### On wafer measured Performance Characteristics (Typical Performance at 25°C)

Vd1 = Vd2 = 20 V, Id1 = 240 mA, Id2 = 640 mA. \*

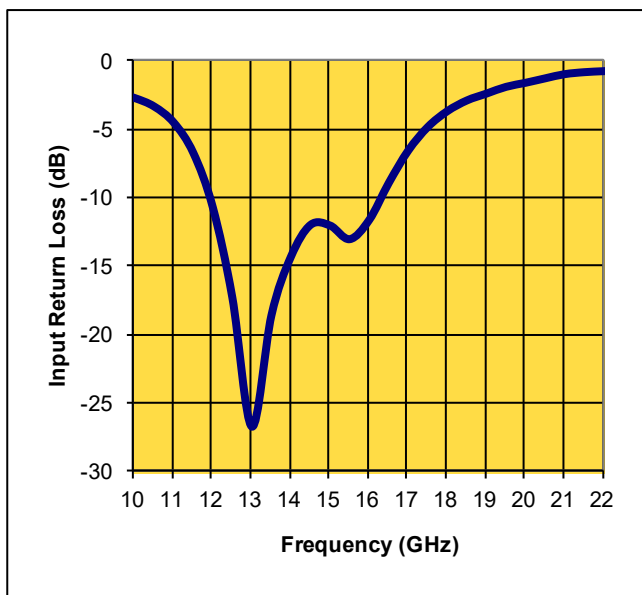
GAIN vs. Frequency



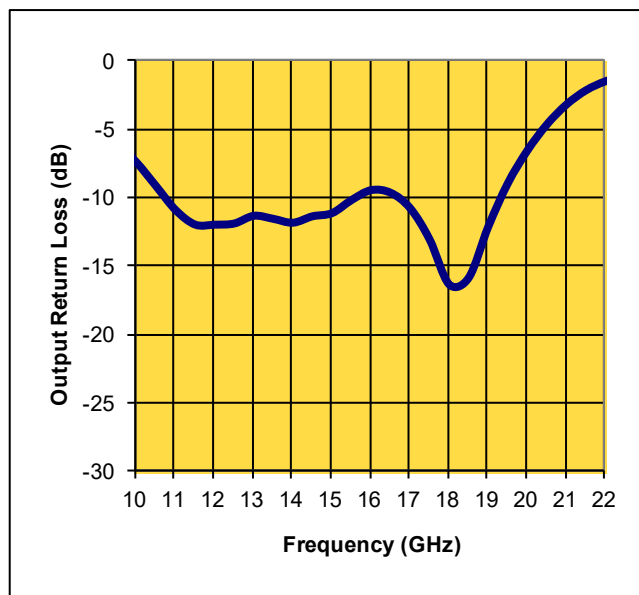
PAE, GAIN, Pout vs. Frequency



Input Return Loss vs. Frequency



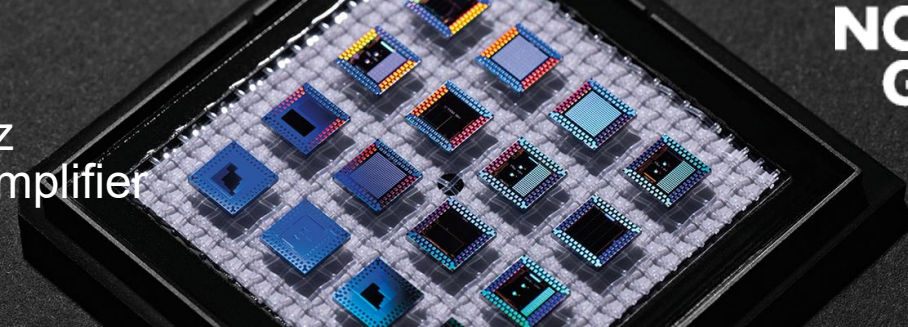
Output Return Loss vs. Frequency



\*Pulsed-power on-wafer

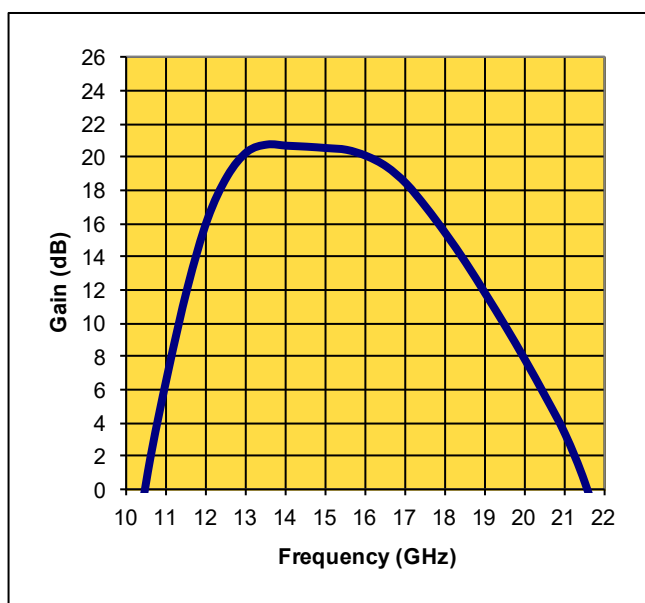
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## APN226 13.5-15.5 GHz GaN Power Amplifier

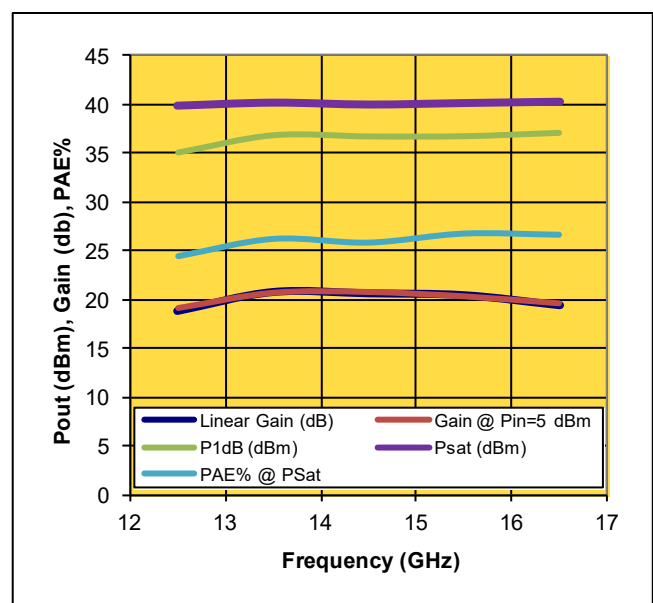


**On wafer measured Performance Characteristics (Typical Performance at 25°C)**  
 $V_{d1} = V_{d2} = 28\text{ V}$ ,  $I_{d1} = 240\text{ mA}$ ,  $I_{d2} = 640\text{ mA}$ . \*

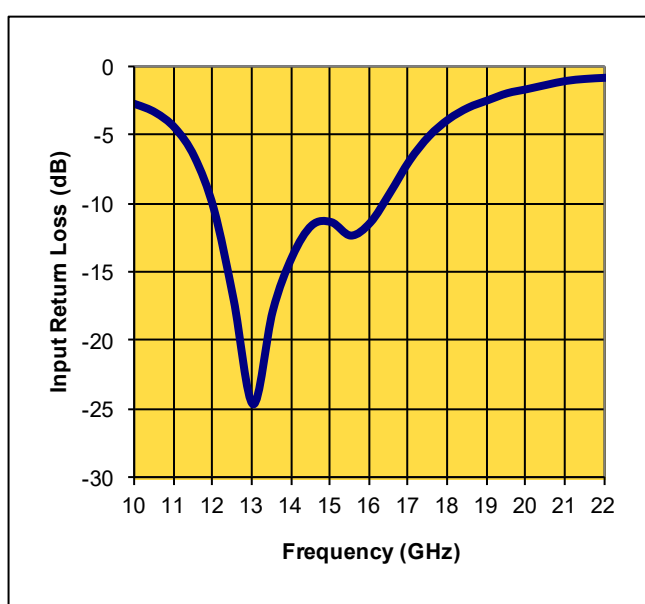
GAIN vs. Frequency



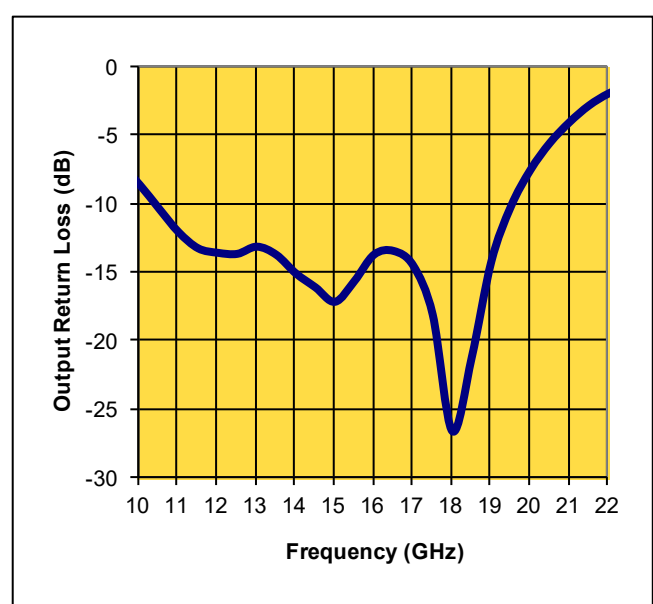
PAE, GAIN, Pout vs. Frequency



Input Return Loss vs. Frequency



Output Return Loss vs. Frequency

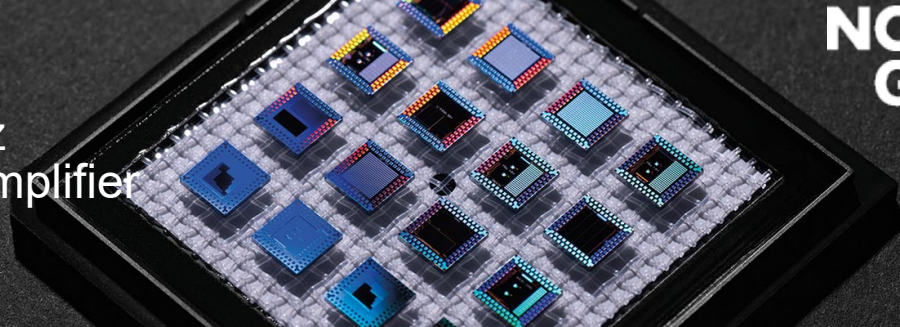


\*Pulsed-power on-wafer

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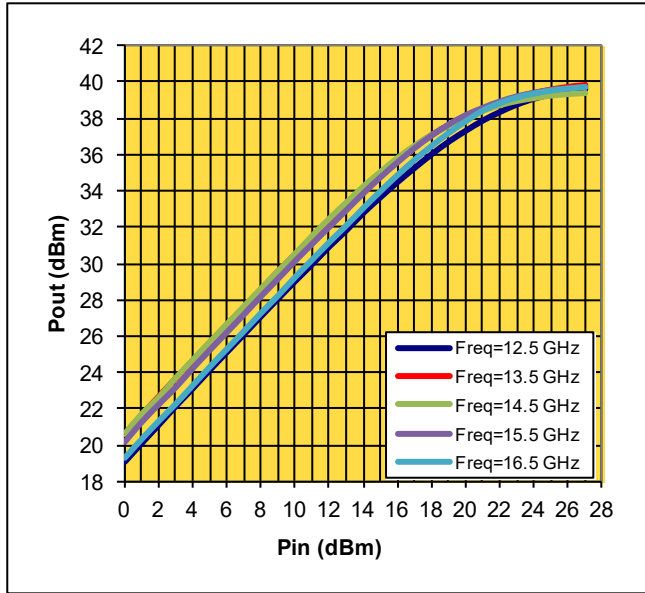


## APN226 13.5-15.5 GHz GaN Power Amplifier

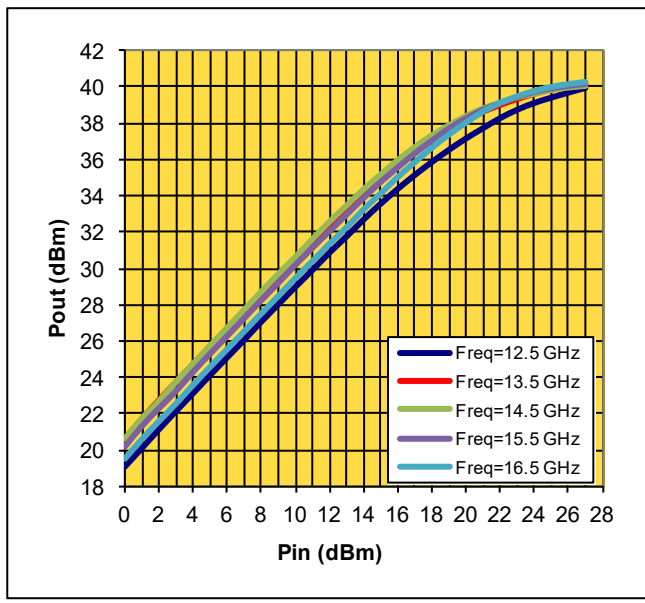


**On wafer measured Performance Characteristics (Typical Performance at 25°C)**  
**Id1 = 240 mA, Id2 = 640 mA. \***

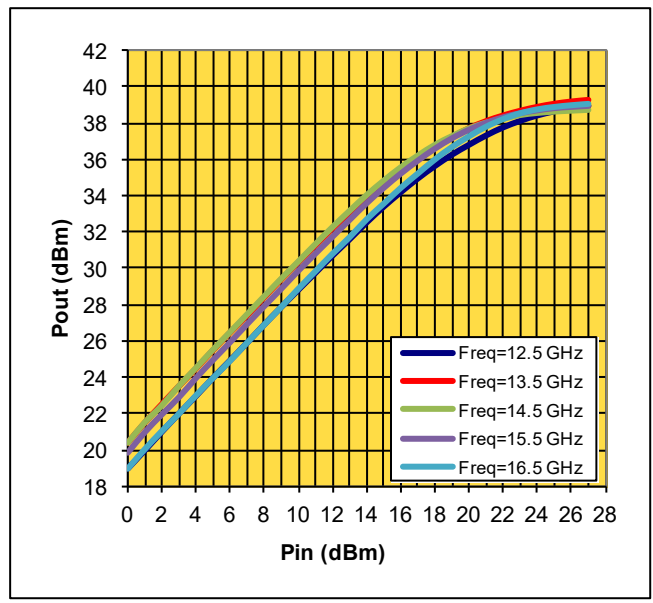
Pout vs. Pin @ Vd1=Vd2=24V



Pout vs. Pin @ Vd1=Vd2=28V



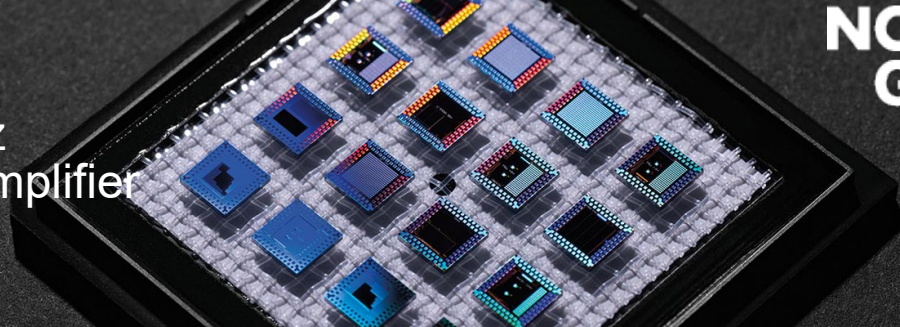
Pout vs. Pin @ Vd1=Vd2=20V



\*Pulsed-power on-wafer

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**APN226**  
**13.5-15.5 GHz**  
**GaN Power Amplifier**



**Thermal Properties**

Preliminary Thermal Properties with die mounted with 1mil 80/20 AuSn Eutectic to 25mil CuW Shim.

Conditions	Shim Boundary Temperature	Junction Temperature T <sub>jc</sub>	Thermal Resistance θ <sub>jc</sub>
V <sub>d</sub> = 24V, I <sub>d1</sub> = 380 mA *	25 °C	159.3 °C	5.3 °C/W
I <sub>d2</sub> + I <sub>d2a</sub> = 1008 mA *	50 °C	196.1 °C	5.8 °C/W
P <sub>in</sub> =26.9 dBm P <sub>out</sub> =39.3 dBm	52.5 °C	200.0 °C **	5.83 °C/W

\* V<sub>d</sub> = 24.0 V, I<sub>dq1</sub> = 240 mA, I<sub>d2q</sub> = 640 mA

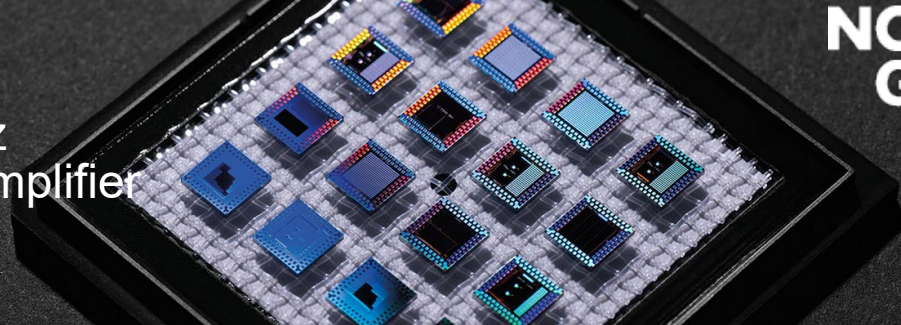
\*\* Max recommended. Pre-qualification reliability testing indicates that MTTF in excess of 10<sup>5</sup> hours can be achieved by ensuring T<sub>jc</sub> is kept below 200°C.

\* Pulsed-Power On-Wafer

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## APN226 13.5-15.5 GHz GaN Power Amplifier



### On wafer measured Performance Characteristics (Typical Performance at 25°C)

Vd1 = Vd2 = 24 V, Id1 = 240 mA, Id2 = 640 mA. \*

Freq GHz	S11 Mag	S11 Ang	S21 Mag	S21 Ang	S12 Mag	S12 Ang	S22 Mag	S22 Ang
8.0	0.461	101.870	3.697	-111.478	0.004	-19.991	0.229	-50.326
8.5	0.305	82.279	5.877	-156.942	0.006	22.788	0.215	-71.266
9.0	0.140	57.241	7.944	156.616	0.006	-11.884	0.209	-83.304
9.5	0.033	-7.924	9.536	110.075	0.004	-57.805	0.223	-95.152
10.0	0.107	-101.508	10.221	65.248	0.007	-38.639	0.217	-111.473
10.5	0.192	-119.288	10.070	25.403	0.002	-170.834	0.204	-115.664
11.0	0.245	-134.405	10.015	-11.781	0.002	-161.559	0.172	-119.745
11.5	0.273	-143.902	10.061	-47.813	0.002	64.799	0.174	-116.071
12.0	0.254	-141.837	9.979	-83.956	0.004	125.238	0.186	-115.597
12.5	0.259	-133.613	9.615	-121.442	0.004	51.271	0.205	-120.465
13.0	0.348	-122.232	8.968	-159.474	0.005	5.375	0.227	-134.886
13.5	0.477	-126.098	8.065	162.641	0.005	-6.692	0.200	-153.352
14.0	0.569	-132.862	6.836	125.406	0.008	-53.726	0.144	-179.669
14.5	0.662	-139.509	5.673	90.341	0.004	-176.720	0.062	117.915
15.0	0.725	-148.466	4.646	55.355	0.003	-141.496	0.101	25.350
15.5	0.769	-155.321	3.720	20.982	0.007	-102.598	0.209	-8.918
16.0	0.807	-160.898	2.978	-12.195	0.002	-161.597	0.322	-25.318
16.5	0.845	-166.839	2.350	-46.408	0.006	111.398	0.433	-39.840
17.0	0.865	-171.744	1.839	-81.138	0.002	-135.188	0.545	-54.065
17.5	0.895	-176.622	1.404	-118.400	0.005	-152.650	0.647	-65.974
18.0	0.910	178.326	1.002	-159.002	0.005	76.670	0.747	-76.390
18.5	0.925	173.710	0.627	159.607	0.009	87.246	0.832	-89.068
19.0	0.923	169.561	0.341	122.484	0.005	-140.272	0.873	-99.611
19.5	0.931	165.925	0.173	92.298	0.010	115.686	0.903	-108.257
20.0	0.934	162.265	0.087	68.801	0.005	68.757	0.918	-116.042
20.5	0.940	159.140	0.043	52.012	0.007	102.110	0.933	-122.749
21.0	0.461	101.870	3.697	-111.478	0.004	-19.991	0.229	-50.326
21.5	0.305	82.279	5.877	-156.942	0.006	22.788	0.215	-71.266
22.0	0.140	57.241	7.944	156.616	0.006	-11.884	0.209	-83.304
22.5	0.033	-7.924	9.536	110.075	0.004	-57.805	0.223	-95.152
23.0	0.107	-101.508	10.221	65.248	0.007	-38.639	0.217	-111.473
23.5	0.192	-119.288	10.070	25.403	0.002	-170.834	0.204	-115.664
24.0	0.245	-134.405	10.015	-11.781	0.002	-161.559	0.172	-119.745

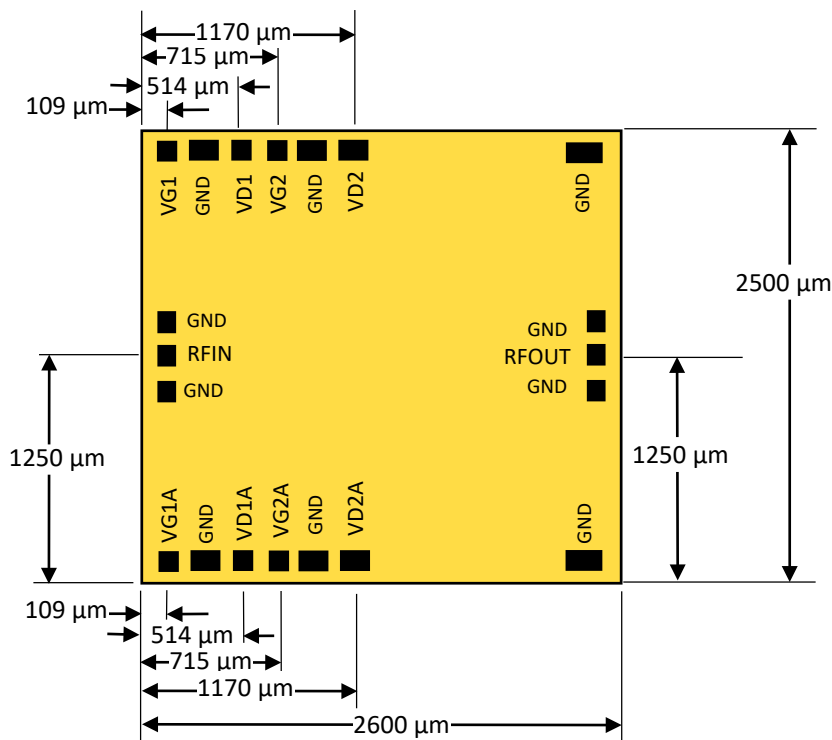
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## APN226 13.5-15.5 GHz GaN Power Amplifier

### Die Size and Bond Pad Locations (Not to Scale)

X =  $2600 \pm 25 \mu\text{m}$   
 Y =  $2500 \pm 25 \mu\text{m}$   
 DC Bond Pad =  $100 \times 100 \pm 0.5 \mu\text{m}$   
 RF Bond Pad =  $100 \times 100 \pm 0.5 \mu\text{m}$   
 Chip Thickness =  $101 \pm 5 \mu\text{m}$



### Biasing/De-Biasing Details:

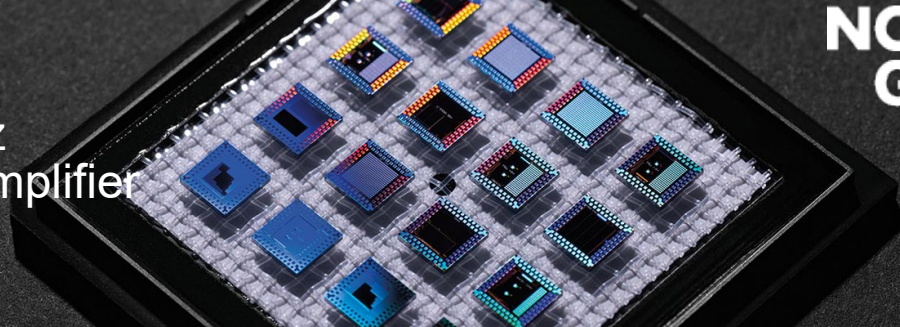
APN226 can be biased from either the top or the bottom of the die.

Listed below are some guidelines for GaN device testing and wire bonding:

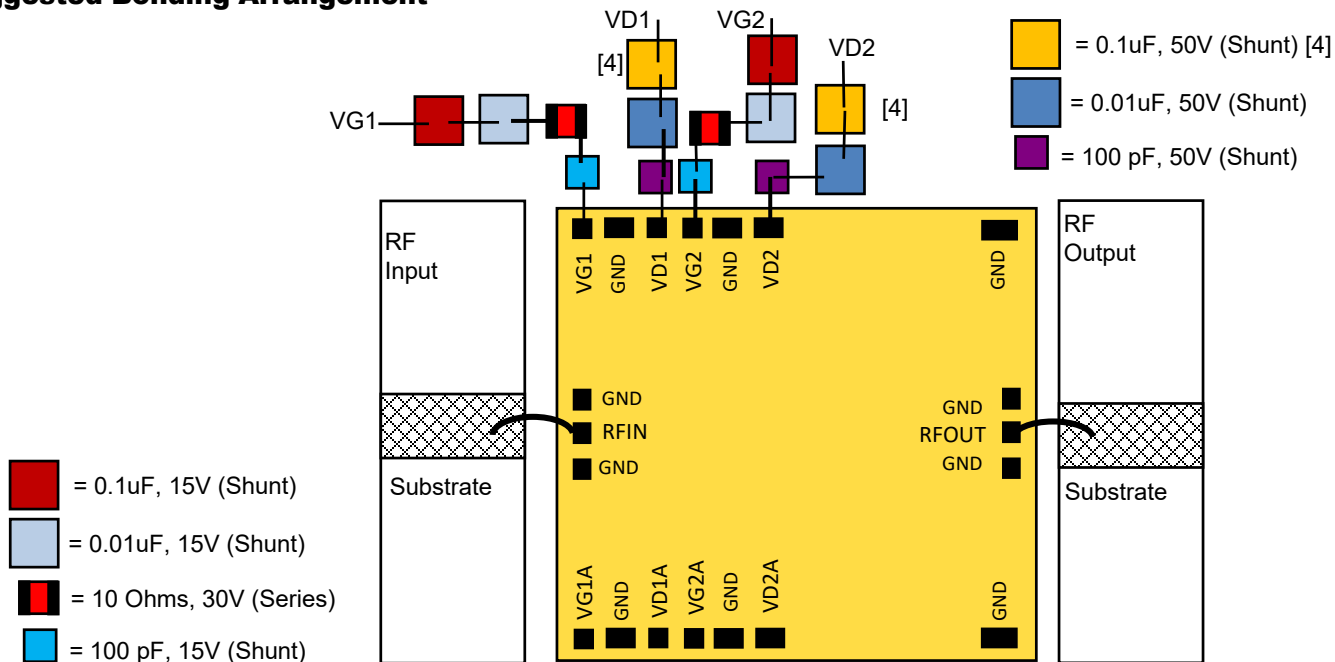
- a. Limit positive gate bias (G-S or G-D) to  $< 1\text{V}$
- b. Know your devices' breakdown voltages
- c. Use a power supply with both voltage and current limit.
- d. With the power supply off and the voltage and current levels at minimum, attach the ground lead to your test fixture.
  - i. Apply negative gate voltage ( $-5\text{ V}$ ) to ensure that all devices are off
  - ii. Ramp up drain bias to  $\sim 10\text{ V}$
  - iii. Gradually increase gate bias voltage while monitoring drain current until 20% of the operating current is achieved
  - iv. Ramp up drain to operating bias
  - v. Gradually increase gate bias voltage while monitoring drain current until the operating current is achieved
- e. To safely de-bias GaN devices, start by debiasing output amplifier stages first (if applicable):
  - i. Gradually decrease drain bias to  $0\text{ V}$ .
  - ii. Gradually decrease gate bias to  $0\text{ V}$ .
  - iii. Turn off supply voltages
- f. Repeat de-bias procedure for each amplifier stage

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## APN226 13.5-15.5 GHz GaN Power Amplifier



### Suggested Bonding Arrangement



**Note:** APN226 can be biased from either the top or bottom and bias pads VG1A, VD1A, VG2A and VGD2A can be used as an alternative to the configuration shown.

### Recommended Assembly Notes

1. Bypass caps should be 100 pF (approximately) ceramic (single-layer) placed no farther than 30 mils from the amplifier.
2. Best performance obtained from use of <10 mil (long) by 3 by 0.5 mil ribbons on input and output.
3. Part must be biased from both sides as indicated.
4. The 0.1uF, 50V capacitors are not needed if the drain supply line is clean. If Drain Pulsing of the device is to be used, do **NOT** use the 0.1uF, 50V Capacitors.

### Mounting Processes

Most NGAS GaN IC chips have a gold backing and can be mounted successfully using either a conductive epoxy or AuSn attachment. NGAS recommends the use of AuSn for high power devices to provide a good thermal path and a good RF path to ground. Maximum recommended temp during die attach is 320°C for 30 seconds.

**Note:** Many of the NGAS parts do incorporate airbridges, so caution should be used when determining the pick up tool.

**CAUTION:** THE IMPROPER USE OF AuSn ATTACHMENT CAN CATASTROPHICALLY DAMAGE GaN CHIPS.

**PLEASE ALSO REFER TO OUR “GaN Chip Handling Application Note” BEFORE HANDLING, ASSEMBLING OR BIASING THESE MMICS!**

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